WEST Search History

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DATE: Friday, April 23, 2004

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		DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=ADJ	
☐	L13	L12 and l6	27
☐	L12	((substrate or wafer or semiconductor) with horizontal) same (clean$3 or wash$3 or rins$3) same (ultrasonic$5 or transducer or megasonic$5 or sonic$5)same (tank or bath or vessel or apparatus)	63
☐	L11	L10 and l6	12
☐	L10	L8 same (shield$3 or lens or reflect$5 or attenuat$3)	32
☐	L9	L8 and l6	98
☐	L8	L7 same rotat$5	383
☐	L7	(substrate or wafer or semiconductor) same (clean$3 or wash$3 or rins$3) same (ultrasonic$5 or transducer or megasonic$5 or sonic$5)same (tank or bath or vessel or apparatus)	3049
☐	L6	134/184,137,147,148,149,157,1.3;311/335;366/127.ccls.	3639
☐	L5	L4 and l1	0
☐	L4	($6methylpyrrolidinone)	3748
☐	L3	L1 and ($6methylpyrrolidinone)	0
☐	L2	L1 and (n-methylpyrrolidinone)	0
☐	L1	scp.as.	187

END OF SEARCH HISTORY